

GEMOLOGICAL INSTITUTE

# **ELECTRONIC COPY**

## LABORATORY GROWN DIAMOND REPORT

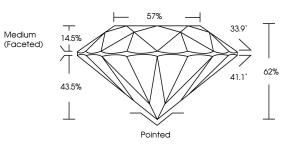
# PROPORTIONS

June 28, 2024	
IGI Report Number	LG640444242
Description	LABORATORY GROWN DIAMOND
Shape and Cutting Style	ROUND BRILLIANT
Measurements	8.41 - 8.45 X 5.22 MM
GRADING RESULTS	
Carat Weight	2.28 CARATS
Color Grade	년 61 동안 61 문
Clarity Grade	VVS 2
Cut Grade	IDEAL

#### ADDITIONAL GRADING INFORMATION

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	(G) LG640444242

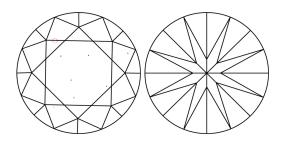
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa



LG640444242

Report verification at igi.org

## **CLARITY CHARACTERISTICS**



## **KEY TO SYMBOLS**

Red symbols indicate internal characteristics. Green symbols indicate external characteristics.



#### Sample Image Used

## COLOR

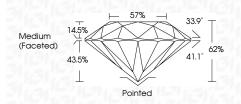
DEF	GHIJ	Faint	Very Light	Light
CLADITY				
CLARITY	VVS <sup>1-2</sup>	VS <sup>1-2</sup>	SI <sup>1-2</sup>	<sup>1-3</sup>
Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included



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G RESULTS	
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rade	F
Grade	VVS 2
de	IDEAL

LABORATORY GROWN DIAMOND REPORT



#### ADDITIONAL GRADING INFORMATION

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С.;

Polish EXCELLENT   Symmetry EXCELLENT   Fluorescence NONE   Inscription(s) Itel Codu444242   Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type Ila		
Fluorescence NONE Inscription(s) (G) LG640444242 Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	Polish	EXCELLENT
Inscription(s) (G) LG640444242 Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	Symmetry	EXCELLENT
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	Fluorescence	NONE
created by Chemical Vapor Deposition (CVD) growth process.	Inscription(s)	1571 LG640444242
	created by Chemical Vapor process.	





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